

| L Number | Hits | Search Text | DB | Time stamp |
|----------|--------|--|---|---------------------|
| 1 | 129513 | silicon near (layer film) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB | 2004/03/16 10:27 |
| 6 | 82047 | remov\$3 near2 heat | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB | 2004/03/16 10:38 |
| 9 | 277075 | (silicon near (oxide dioxide)) (sio."sub.2") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB | 2004/03/16 10:38 |
| 12 | 22017 | SOI (silicon near on near insulator) (silicon-on-insulator) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB | 2004/03/16 10:40 |
| 13 | 246 | (silicon near (layer film)) and (remov\$3 near2 heat) and ((silicon near (oxide dioxide)) (sio."sub.2")) and (SOI (silicon near on near insulator) (silicon-on-insulator)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB | 2004/03/16 10:40 |